

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	27	(stage table wst) near (substrate wafer object) and (lyophilic hydrophilic liquidphilic philic affinity) near (recover\$1)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/08/13 16:42
L2	57	(stage table support chuck) near (substrate wafer object workpiece) same (lyophilic hydrophilic liquidphilic philic affinity) with (recover\$3 remov \$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/08/13 16:42
L3	20	(stage table support chuck) near (substrate wafer object workpiece) same (lyophilic hydrophilic liquidphilic philic affinity) with (recover\$3 remov \$3) and (\$5lithograph\$2 exposure).ti.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/08/13 16:42

L4	0	(stage table support chuck) near (substrate wafer object workpiece) same (lyophilic hydrophilic liquidphilic philic affinity) with (protrud\$3 overhang\$3) and (\$5lithograph\$2 exposure).ti.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/08/13 16:42
L5	42	(stage table support chuck) near (substrate wafer object workpiece) same (protrud\$3 overhang\$3) same (recover\$3 remov \$3) and (\$5lithograph\$2 exposure).ti.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/08/13 16:42
L6	36	(stage table support chuck) near (substrate wafer object workpiece) same (protrud\$3 overhang\$3) same (recover\$3 remov \$3) with (liquid fluid immersion) and (\$5lithograph \$2 exposure).ti.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/08/13 16:42

8/13/2010 4:43:14 PM

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